## Origin of anisotropic spin current generation in collinear antiferromagnetic RuO<sub>2</sub>

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Electronic topology in antiferromagnetic (AFM) materials even without spin-orbit interaction (SOI) plays an important role for spin accumulation and/or spin current generation. Recently a novel effect called as magnetic spin Hall effect (MSHE) has been discovered in non-collinear AFM Weyl semimetal Mn<sub>3</sub>Sn [M. Kimata *et al*, *Nature* **565**, 627 (2019)]. An efficiency of the spin current generation depends on the Néel vector direction especially the sign in this Mn<sub>3</sub>Sn case. It is expected that the MSHE opens a new avenue both for fundamental physics and application on spintronics. In this study, we focus on a simple collinear AFM RuO<sub>2</sub> with rutile structure to understand the origin of spin current generation which is governed either by the topology such as Dirac nodal line or by the AFM order.

We fabricated epitaxial RuO<sub>2</sub> (101) and (100) films by means of rf magnetron sputtering using single crystalline sapphire substrates with optimized annealing temperatures. As shown in Fig. (a), We observed the single peak around  $35^{\circ}$  in X-ray diffraction and streak pattern after the 5 nm sputtering in reflection high energy electron diffraction, confirming the epitaxial RuO<sub>2</sub> (101) phase. Further we employed the harmonic Hall measurement to evaluate both damping-like (DL) and field-like torque. Surprisingly, for RuO<sub>2</sub> (101) film, we found the anisotropy of the DL torque depending on applied current direction along to the in-plane crystal direction as shown in Fig. (b). This anisotropy seems to be originated from the Néel vector direction because the vector is canted like Fig. (c) as for the RuO<sub>2</sub> (101). For further verification on the origin of the induced anisotropy in DL torque, we compare the angle dependence of DL torque in RuO<sub>2</sub>(100) films which has perpendicular Néel vector (Fig. (c)).



Figure (a) X-ray diffraction pattern and reflection high energy electron diffraction image in-situ for RuO<sub>2</sub>(101).
(b) DL spin-orbit field as a function of current direction along to the crystal angle \$\phi\_C\$.
(c) N(a) sector coefficient on (101) and (100) crystal along and achematic image for the sector.

(c) Néel vector configuration on (101) and (100) crystal plane and schematic image for the  $\phi_{C}$  scan.